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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/543,050	12/12/2005	Kenichi Ishibashi	S1459.70081US00	2592
	7590 02/27/200 IFIELD & SACKS, P.0	EXAMINER		
600 ATLANTIC AVENUE			NOVACEK, CHRISTY L	
BOSTON, MA 02210-2206			ART UNIT	PAPER NUMBER
			2822	
			MAIL DATE	DELIVERY MODE
			02/27/2009	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

	Application No.	Applicant(s)
	10/543,050	ISHIBASHI ET AL.
Office Action Summary	Examiner	Art Unit
	CHRISTY L. NOVACEK	2822
The MAILING DATE of this communication a Period for Reply	ppears on the cover sheet with the o	correspondence address
A SHORTENED STATUTORY PERIOD FOR REF WHICHEVER IS LONGER, FROM THE MAILING - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period. - Failure to reply within the set or extended period for reply will, by stat Any reply received by the Office later than three months after the mai earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNICATION 1.136(a). In no event, however, may a reply be tired will apply and will expire SIX (6) MONTHS from the cause the application to become ABANDONE	N. nely filed the mailing date of this communication. ED (35 U.S.C. § 133).
Status		
Responsive to communication(s) filed on 21 This action is FINAL . 2b) ☑ The 3) ☐ Since this application is in condition for allow closed in accordance with the practice under	nis action is non-final. vance except for formal matters, pro	
Disposition of Claims		
4) Claim(s) 1-15 is/are pending in the application 4a) Of the above claim(s) is/are withdrest is/are allowed. 5) Claim(s) is/are allowed. 6) Claim(s) 1-15 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and are subjected to by the Examination of the drawing(s) filed on is/are: Applicant may not request that any objection to the subjection to the subjection of the subject	rawn from consideration. I/or election requirement. ner. ccepted or b) □ objected to by the	
Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the	ection is required if the drawing(s) is ob	jected to. See 37 CFR 1.121(d).
Priority under 35 U.S.C. § 119		
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority docume 2. Certified copies of the priority docume 3. Copies of the certified copies of the priority docume application from the International Bure * See the attached detailed Office action for a li	ents have been received. ents have been received in Applicat riority documents have been receive eau (PCT Rule 17.2(a)).	ion No ed in this National Stage
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date 07/21/2005, 05/05/2006, 07/25/2006, 03/11/2008	4) Interview Summary Paper No(s)/Mail D 5) Notice of Informal F 02/04/2008. 6) Other:	ate



Application No.

DETAILED ACTION

This office action is in response to the communication filed July 21, 2005.

Information Disclosure Statement

The information disclosure statement filed July 25, 2006 fails to comply with 37 CFR 1.98(a)(3) because it does not include a concise explanation of the relevance, as it is presently understood by the individual designated in 37 CFR 1.56(c) most knowledgeable about the content of the information, of each publication listed that is not in the English language.

Therefore, the references of Ngamsinlapasathian, Adachi and Murata have not been considered.

On the information disclosure statement filed February 4, 2008, the reference of "US 2002/289269" has not been considered because no US published patent application having that number exists.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nakamura et al. (US 20020015881), cited in IDS in view of Yoshikawa (US 6,586,670), cited in IDS.

Regarding claims 1, 6, 10, 11, 13 and 14, Nakamura discloses making a photoelectric conversion device, coating a paste containing a mixture of semiconductor fine grain particles

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(21) and a polymer compound binder onto a transparent conductive substrate (50), sintering to form a semiconductor layer (20) made of the semiconductor fine grain particles, and, after the semiconductor layer is formed, irradiating ultraviolet rays onto the semiconductor layer (Fig. 1, ¶ 0023-0024, 0044-0062). Nakamura discloses that heat treatment causes "unnecessary matter" to be removed from the semiconductor layer, but Nakamura does not specifically disclose that the removing organic material (¶ 0062). Like Nakamura, Yoshikawa discloses making a photoelectric conversion device by coating a paste containing semiconductor fine particles and a binder on a substrate (Abstract). Yoshikawa discloses that heat treatment combined with applying an UV ray works to remove unnecessary organic compounds (col. 20, ln. 31-35). At the time of the invention, it would have been obvious to one of ordinary skill in the art to use the heat/UV treatment process of Nakamura to rid the semiconductor layer of organic substances because Nakamura states that the heat treatment removes unnecessary matter and Yoshikawa states that heat/UV treatment removes unnecessary organic compounds.

Regarding claim 2, Nakamura discloses one or more kinds of semiconductor fine grain particles exhibiting photocatalyst activity may be used as the semiconductor fine grain particles (¶ 0039).

Regarding claim 3, Nakamura discloses that the semiconductor fine grain particles can be made of titanium oxide, zinc oxide or strontium titanate (¶ 0035-0036).

Regarding claim 4, Nakamura discloses that the polymer compound improves the viscosity of the paste (¶ 0045).

Regarding claim 5, Nakamura discloses that the polymer compound improving viscosity can by polyethylene glycol (¶ 0045).

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Regarding claims 7-9, 12 and 15, at the time of the invention, it would have been obvious to one of ordinary skill in the art to use routine experimentation to adjust the heat/UV treatment of Nakamura in order to control the evaporation of the organic substance therein because Nakamura discloses removing unnecessary substances from the film and Yoshikawa discloses using heat/UV treatment to remove unnecessary organic compounds.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Christy L. Novacek whose telephone number is (571) 272-1839. The examiner can normally be reached on Monday-Friday 12:00pm - 6:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Zandra Smith can be reached on (571) 272-2429. The fax phone number for the organization where this application or proceeding is assigned is (571) 273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

CLN February 23, 2009

/N. Drew Richards/ Supervisory Patent Examiner, Art Unit 2895